

## Supplementary material

### **Tunable Schottky contacts in graphene/XAu<sub>4</sub>Y (X, Y = Se, Te) heterostructures**

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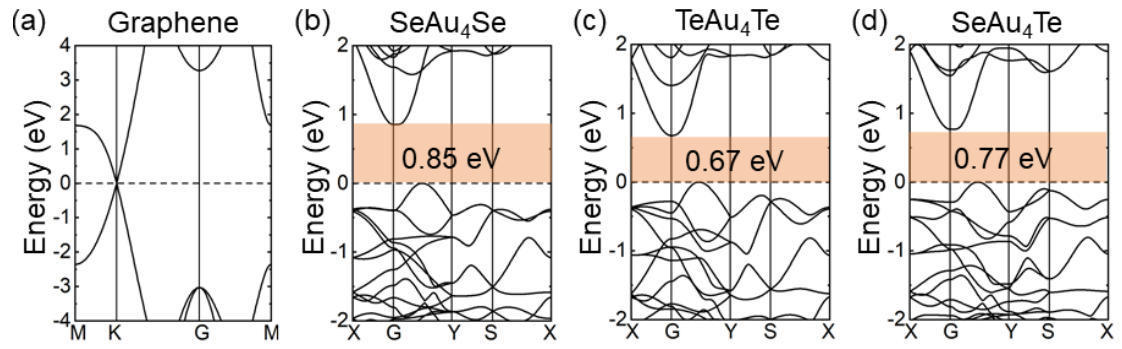
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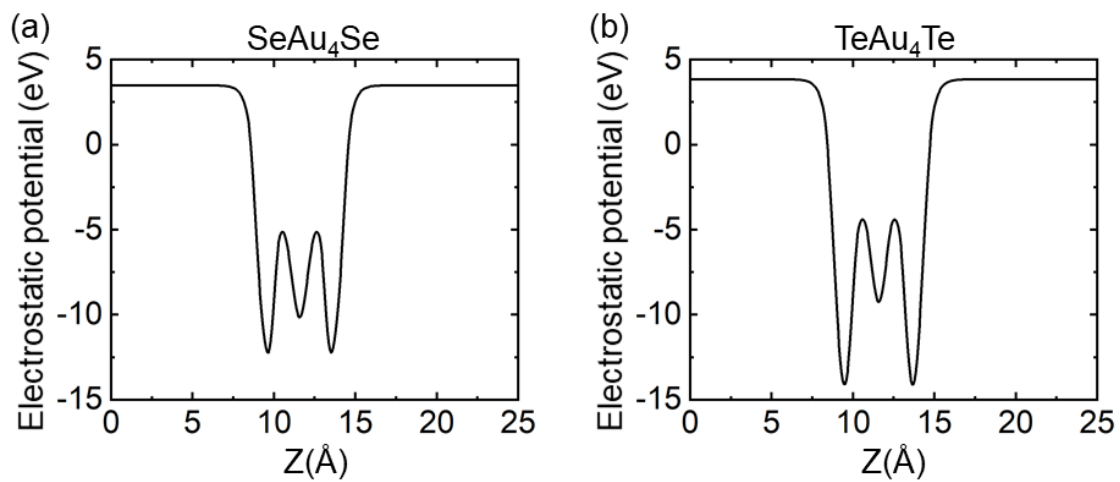
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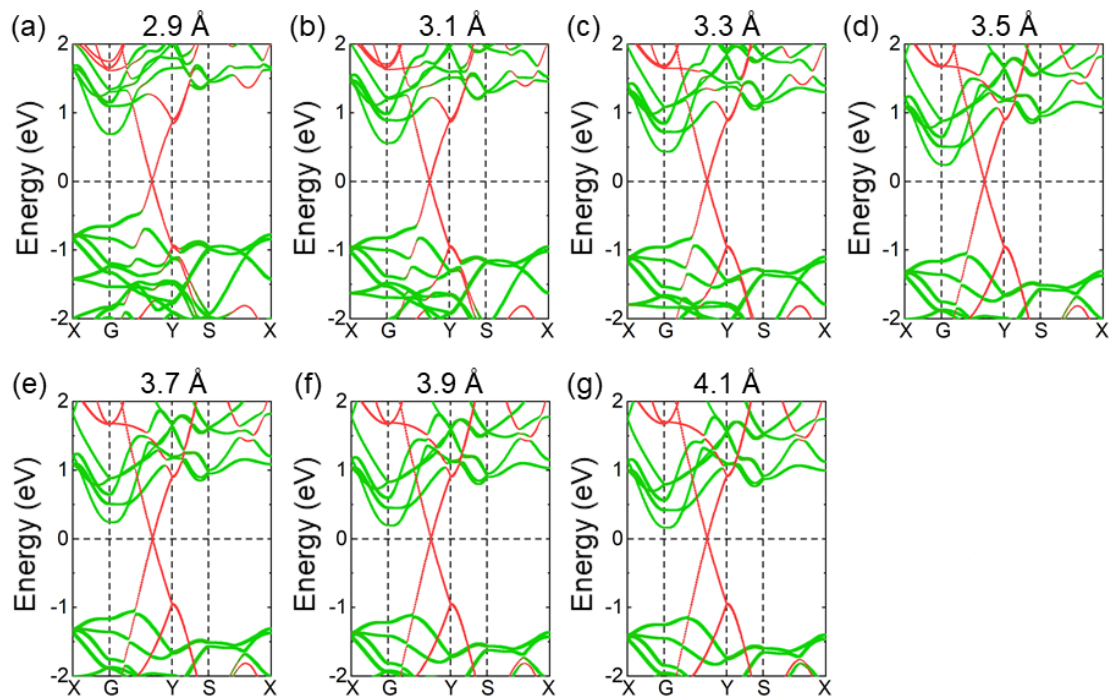
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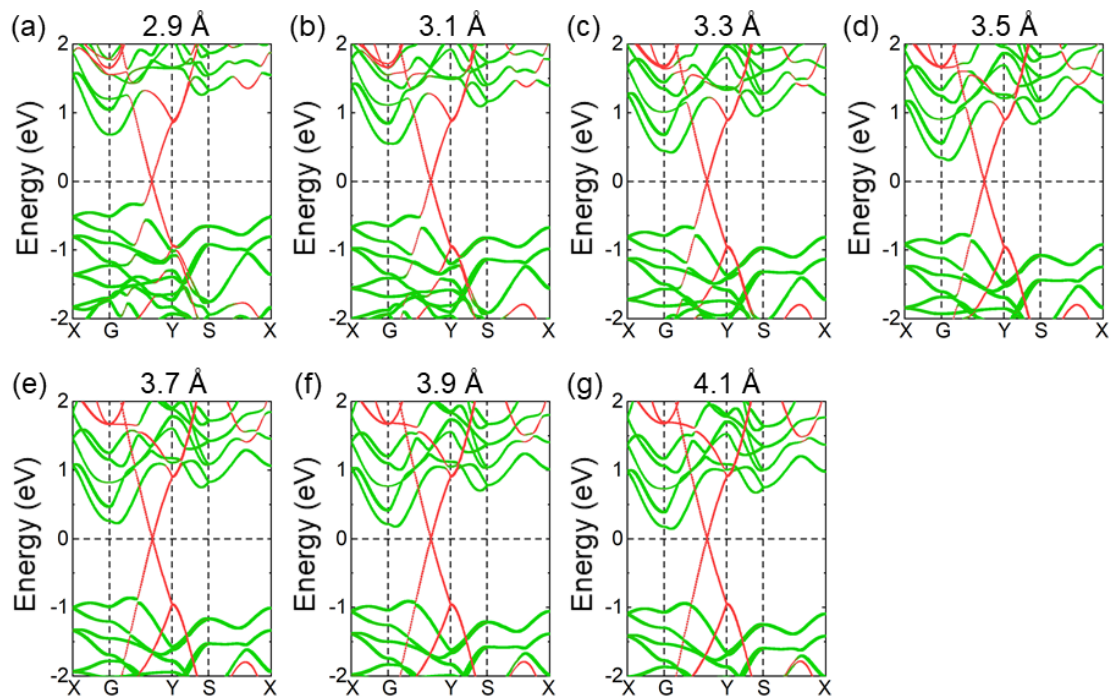
**Figure S1** Energy band structures of (a) graphene, (b)  $\text{SeAu}_4\text{Se}$ , (c)  $\text{TeAu}_4\text{Te}$  and (d)  $\text{SeAu}_4\text{Te}$  monolayers, respectively.



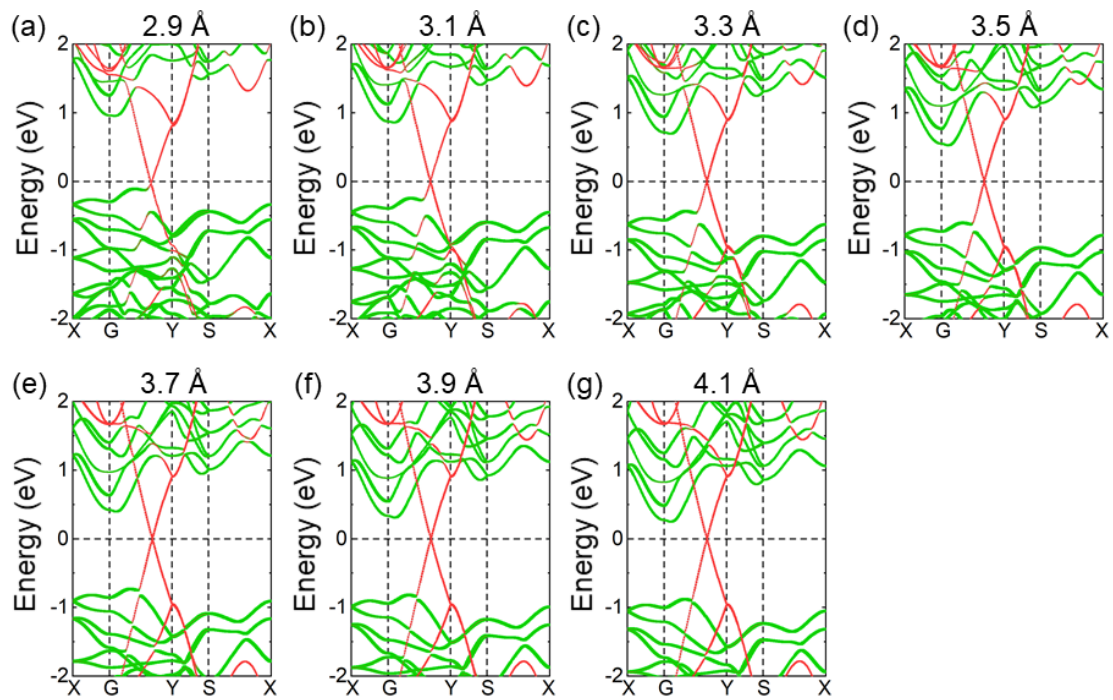
**Figure S2** Electrostatic potentials of (a) SeAu<sub>4</sub>Se and (b) TeAu<sub>4</sub>Te monolayers, respectively.



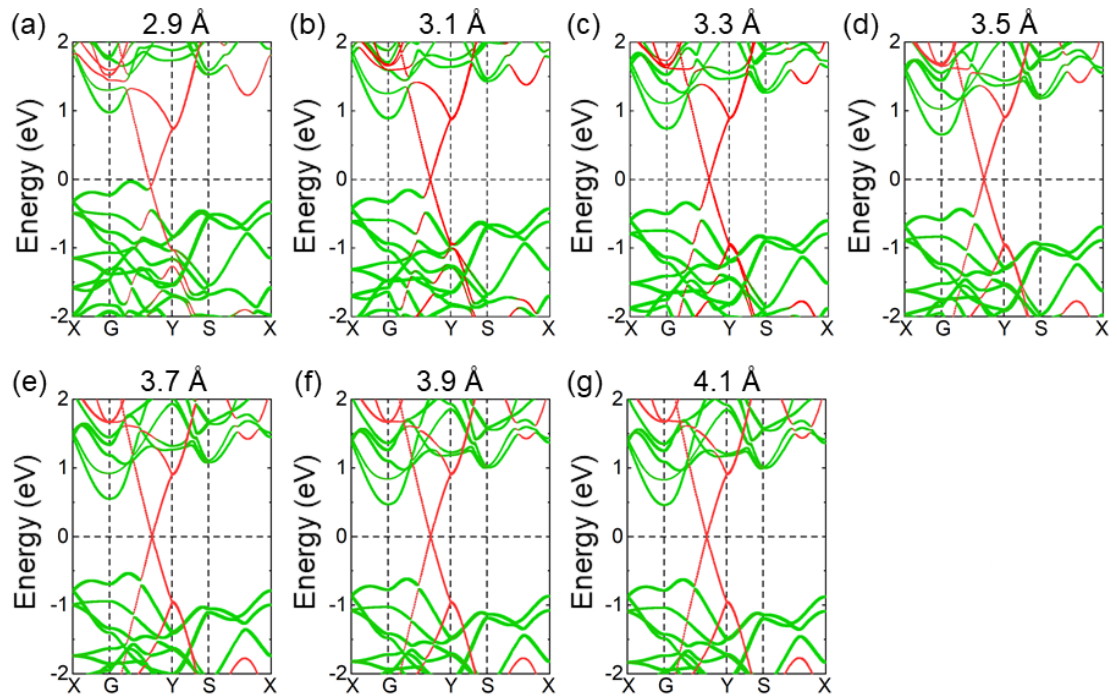
**Figure S3** (a)-(g) Projected band structures of G/SeAu<sub>4</sub>Se heterostructure with different interlayer distances. The contributions of G and SeAu<sub>4</sub>Se monolayers are marked by red and green, respectively.



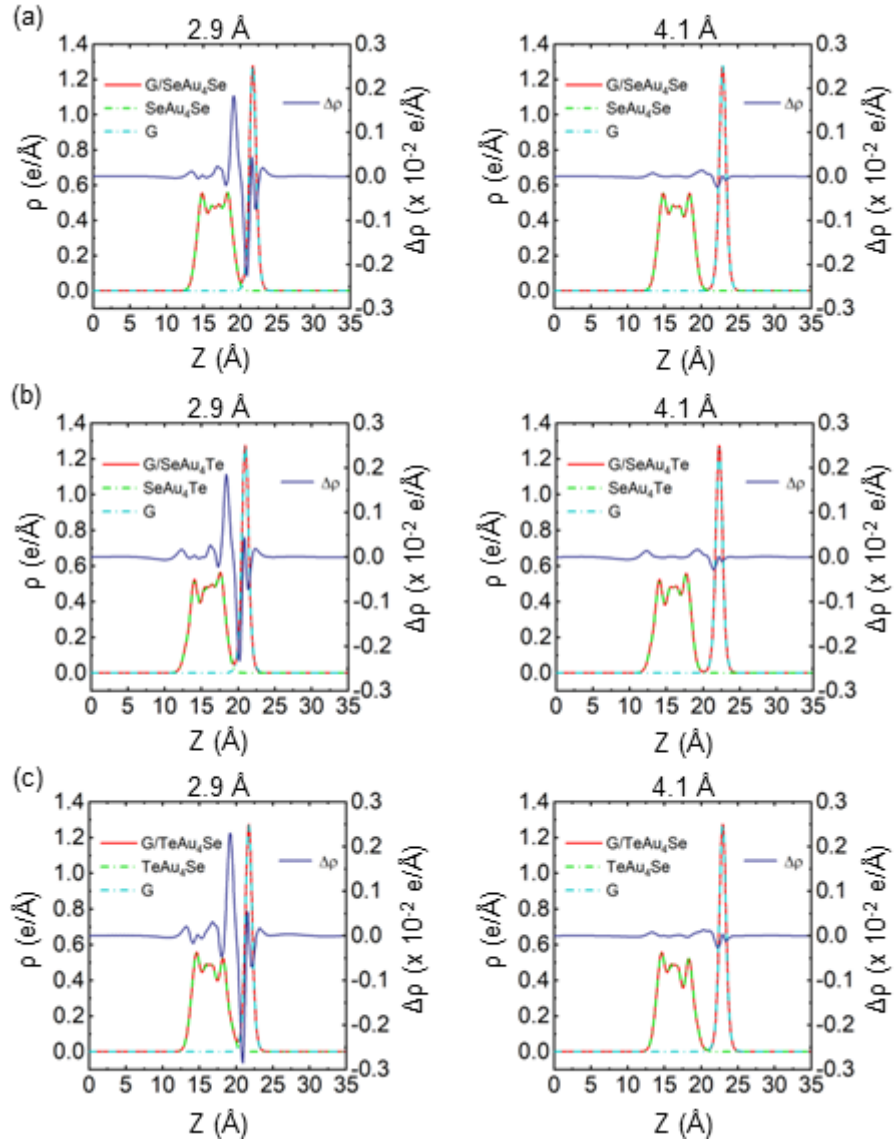
**Figure S4** (a)-(g) Projected band structures of G/SeAu<sub>4</sub>Te heterostructure with different interlayer distances. The contributions of G and SeAu<sub>4</sub>Te monolayers are marked by red and green, respectively.



**Figure S5** (a)-(g) Projected band structures of G/TeAu<sub>4</sub>Se heterostructure with different interlayer distances. The contributions of G and TeAu<sub>4</sub>Se monolayers are marked by red and green, respectively.

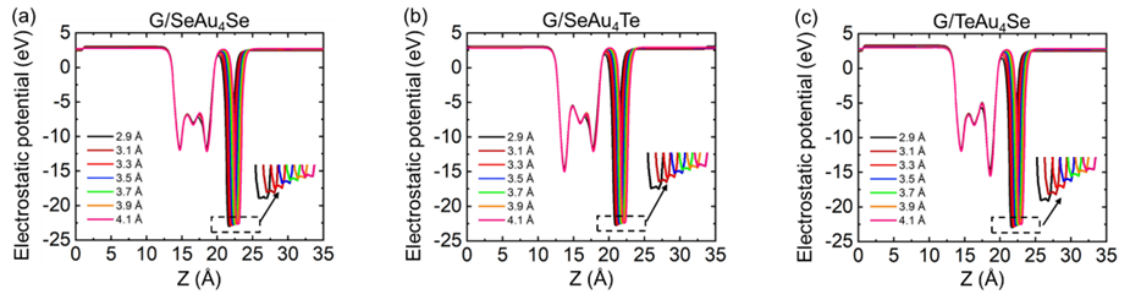


**Figure S6** (a)-(g) Projected band structures of G/TeAu<sub>4</sub>Te heterostructures with different interlayer distances. The contributions of G and TeAu<sub>4</sub>Te monolayers are marked by red and green, respectively.

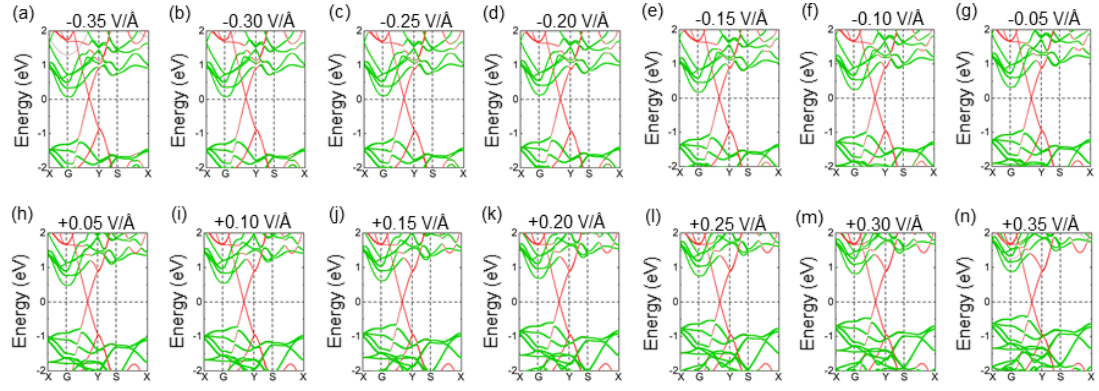


**Figure S7** Charge density differences of (a) G/SeAu<sub>4</sub>Se, (b) G/SeAu<sub>4</sub>Te and (c) G/TeAu<sub>4</sub>Se heterostructures with interlayer distances of 2.9 and 4.1 Å. The charge density difference of heterostructures is denoted by blue solid line. The charge densities of G/XAu<sub>4</sub>Y, G and XAu<sub>4</sub>Y are denoted by red solid lines, cyan and green dotted lines, respectively.

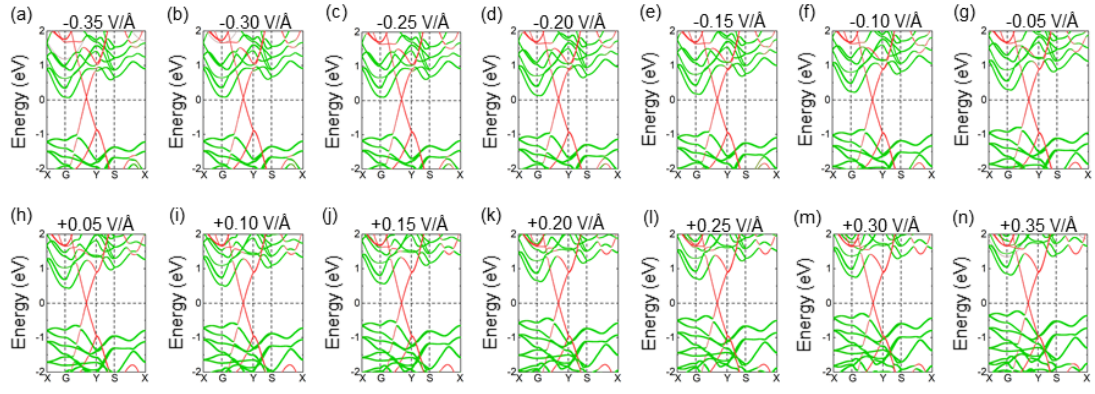




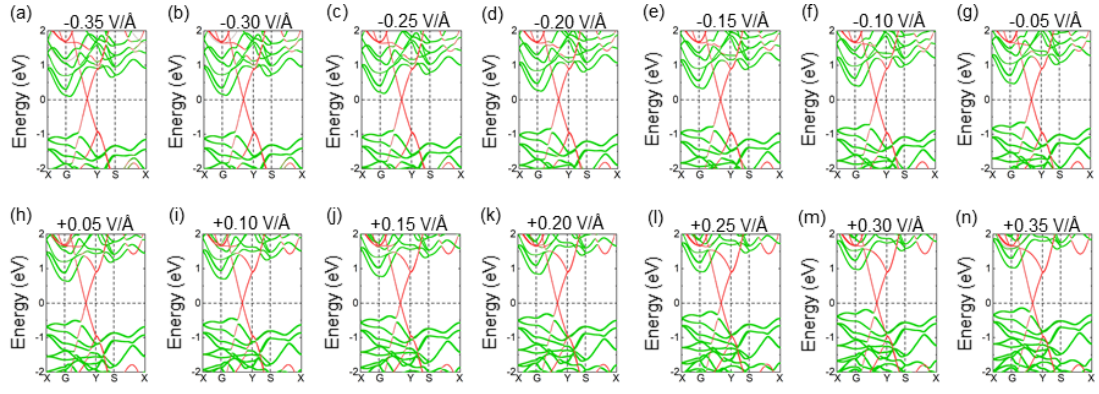
**Figure S8** Electrostatic potentials of (a) G/SeAu<sub>4</sub>Se, (b) G/SeAu<sub>4</sub>Te and (c) G/TeAu<sub>4</sub>Se heterostructures with interlayer distances from 2.9 to 4.1 Å. With the interlayer distance decreasing, the amount of transferred electrons increases, and meanwhile, the potential well of G notably becomes deeper, leading to a stronger interfacial electrostatic field.



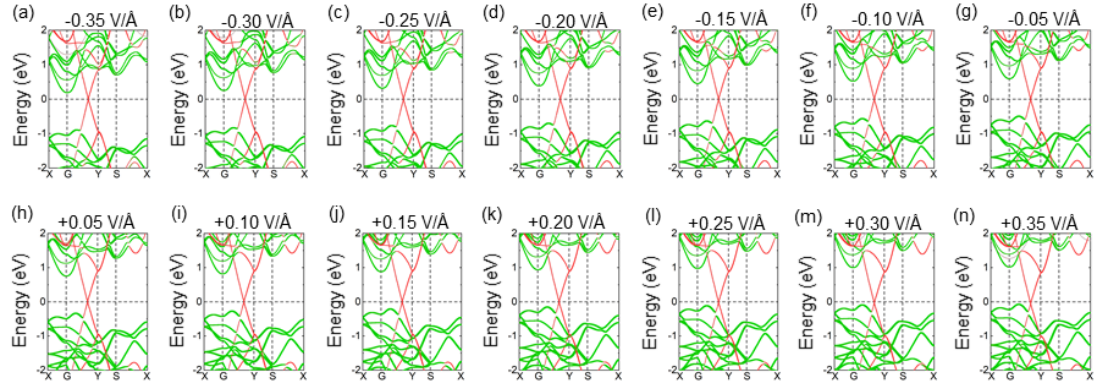
**Figure S9** (a)-(n) Projected band structures of G/SeAu<sub>4</sub>Se heterostructures with -0.35 to +0.35 V/Å electric fields. The contributions of G and SeAu<sub>4</sub>Se monolayers are marked by red and green, respectively.



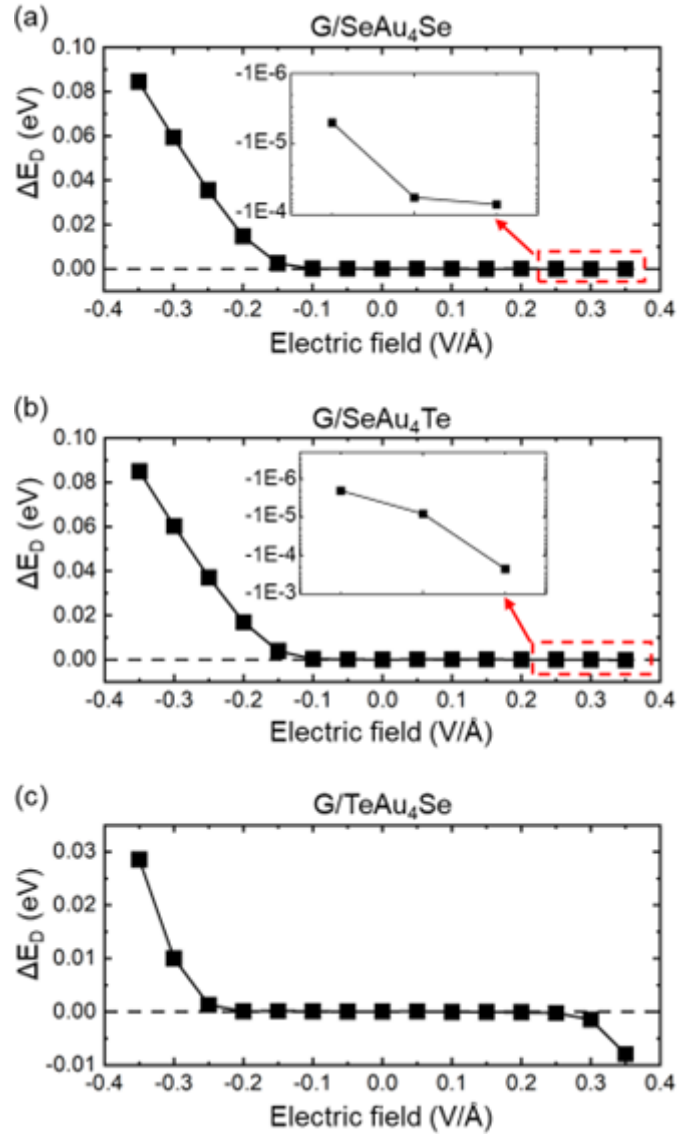
**Figure S10** (a)-(n) Projected band structures of G/SeAu<sub>4</sub>Te heterostructures with -0.35 to +0.35 V/Å electric fields. The contributions of G and SeAu<sub>4</sub>Te monolayers are marked by red and green, respectively.



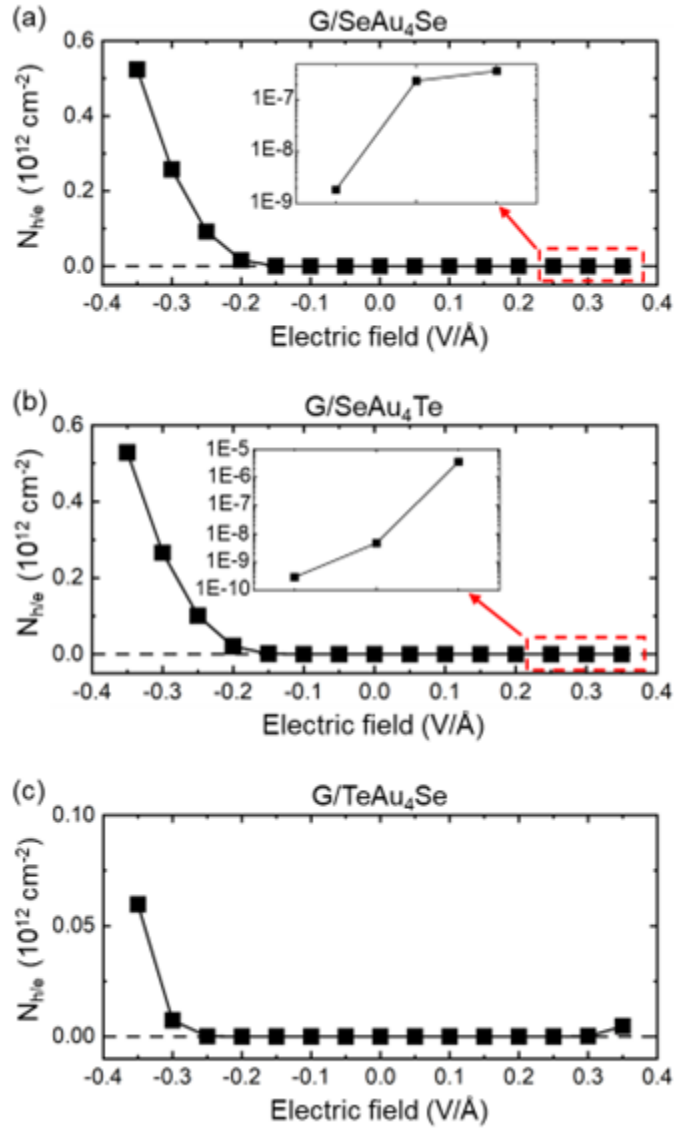
**Figure S11** (a)-(n) Projected band structures of G/TeAu<sub>4</sub>Se heterostructures with -0.35 to +0.35 V/Å electric fields. The contributions of G and TeAu<sub>4</sub>Se monolayers are marked by red and green, respectively.



**Figure S12** (a)-(n) Projected band structures of G/TeAu<sub>4</sub>Te heterostructures with -0.35 to +0.35 V/Å electric fields. The contributions of G and TeAu<sub>4</sub>Te monolayers are marked by red and green, respectively.



**Figure S13** Energy shift of graphene's Dirac cone with respect to the Fermi level for (a) G/SeAu<sub>4</sub>Se, (b) G/SeAu<sub>4</sub>Te and (c) G/TeAu<sub>4</sub>Se as a function of electric field from -0.35 to +0.35 V/Å.



**Figure S14** Doping charge carrier concentrations of graphene in (a) G/SeAu<sub>4</sub>Se, (b) G/SeAu<sub>4</sub>Te and (c) G/TeAu<sub>4</sub>Se as a function of electric field from -0.35 to +0.35 V/Å. The hole (electron) doping charge carrier concentrations of graphene correspond to  $\Delta E_D > 0$  ( $\Delta E_D < 0$ ) in figure S13.

**Table S1** The structural parameters and dipole moments of SeAu<sub>4</sub>Se, TeAu<sub>4</sub>Te, SeAu<sub>4</sub>Te monolayers, respectively.

Monolayer	$a$ (Å)	$b$ (Å)	Dipole moments (Debye)
SeAu <sub>4</sub> Se	7.54	5.25	0.00
TeAu <sub>4</sub> Te	7.92	5.36	0.00
SeAu <sub>4</sub> Te	7.72	5.31	0.22